

IN THE U.S. PATENT AND TRADEMARK OFFICE

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Int'l App. No.: PCT/JP03/09097

Application No.: **NEW APPLICATION**

Filed: January 18, 2005

For: MICRO REACTOR DEVICE AND METHOD OF
MANUFACTURING MICRO REACTOR
DEVICE

PRELIMINARY AMENDMENT

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January 18, 2005

Sir:

The following preliminary amendments and remarks are respectfully submitted in connection with the above-identified application. Prior to examination of the present application, please consider the following:

Amendments to the Claims begin on page 2 of this Preliminary Amendment.